

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Noriyuki MATSUKAZE et al.

Serial No.: NEW APPLICATION

Group Art Unit:

Filed: February 27, 2004

Examiner:

For: ORGANIC THIN FILM MANUFACTURING METHOD AND MANUFACTURING APPARATUS

**INFORMATION DISCLOSURE STATEMENT**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

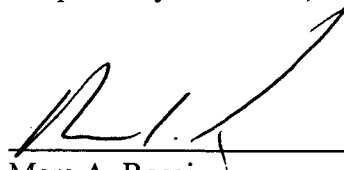
Sir:

Pursuant to 37 C.F.R. §1.56, the attention of the Patent and Trademark Office is hereby directed to the references listed on the attached Form PTO-1449. Copies of the references listed on Form PTO-1449 are attached. Please note that WO 99/25894 corresponds to JP 2001-523768, copies of which are attached.

It is respectfully requested that the information be expressly considered during the prosecution of this application, that these references be made of record therein and appear among the "References Cited" on any patent to issue therefrom, and that an initialed copy of the PTO-1449 be returned to the undersigned.

Respectfully submitted,

Date: 62/27/04

  
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## INFORMATION DISCLOSURE CITATION

(Use several sheets if necessary)

Docket Number (Optional) FUJI:301

SERIAL NO.: NEW APPLICATION

APPLICANT(s) Noriyuki MATSUKAZE et al.

FILING DATE: February 27, 2004

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## U.S. PATENT DOCUMENTS

EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE

## FOREIGN PATENT DOCUMENTS

	REF	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION	
							YES	NO
/RB/	JP	2003-7464 A	1/03	JAPAN (English Abstract)			X	
/RB/	PCT	WO 99/25894	5/99	PCT				
/RB/	JP	2001-523768 A	11/01	JAPAN			X	

## OTHER DOCUMENT(S) (Including Author, Title, Date, Pertinent Pages, Etc.)

EXAMINER	Richard Bueker/		DATE CONSIDERED 09/28/2008

\*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.